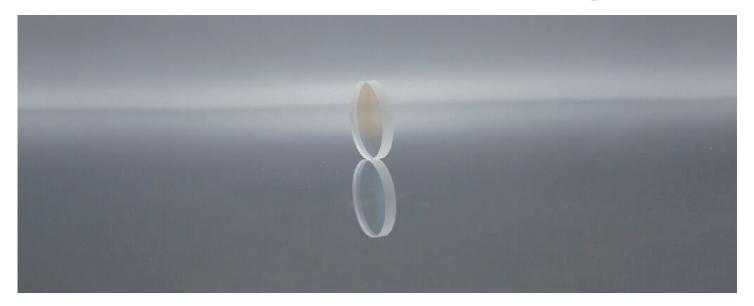


Er:YAG Laser-2940nm-Turning Mirror



DESCRIPTION

Our turning mirrors use high-quality substrate materials, including sapphire and Corning 7980 substrates, and use high-reflection (HR) coating technology to provide extremely high reflection efficiency in the operating wavelength range of 355nm~2940nm, high precision Processing effectively reduces light scattering. Within a certain incident angle range, the reflectivity of the HR film layer to natural light or S-polarized light and P-polarized light can be as high as 99.9% or even close to 100%. It has excellent performance and can be applied to various high-precision lasers.

PROCESSING INDEX

Parallelism	10 ″	
Perpendicularity	5 ´	
Surface Finish	20-10	
Flatness	λ / 8 @ 632 nm	
Clear Aperture	> 85% central area	
Chamfer	0.2mm-0.5mm @ 45°	
Dimensional Accuracy	± 0.05mm	
Thickness/Diameter Tolerance	(0,-0.1)mm	
Damage Threshold	>10 J/cm ² @ 1064nm 10ns 10 Hz	





Er:YAG Laser-2940nm-Turning Mirror

PRODUCT LIST - CORNING 7980 (MATERIAL OPTIONAL)

Model	Size	Form	Coating
CL-TM20001	 Ø = 25.4 mm (-0.1 mm) t = 3 mm (±0.1 mm) 	Front Side (S2) plane Rear Side (S1) plane	Front Side (S2) HRu(45°,2940nm)>99% Ru(45°,635-655nm)<20%
CL-TM20002	∅ = 25 mm (-0.1 mm) t = 3.05 mm (±0.1 mm)	Front Side (S2) plane Rear Side (S1) plane	Front Side (S2) HRu(45°,2940nm)>99.5% Ru(45°,635-655nm)>95%

